3. New Synthetic Route to Polyhedral Organylsilsesquioxanes

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Hydrosilation of methylenecyclohexane and hex-1-ene by octa(hydridosilsesquioxane) catalysed by hexachloroplatinic acid is a new route to polyhedral organylsilsesquioxanes. Quantitative yield of octa(cyclohexylmethylsilsesquioxane) is reached. This reaction opens a vast field of yet unknown polyhedral silsesquioxanes.

Polyhedral silsesquioxanes represent a versatile group of three-dimensional oligomeric organosilicon compounds of the general formula $(\text{RSiO}_{3/2})_n$ (n = 8, 10, 12, ...) [1]. The resemblance of the framework structure of octasilsesquioxanes to the double four ring in zeolites A and CoAPO-50 [2] has attracted our interest in using them as model compounds for investigating these systems [3]. They are appealing to look at as a framework for building donor/acceptor systems A/D of the type A-Si(OSiO)_nSi-D, n = 1, 2. Chemically linked donor/acceptor systems are used in studies on long-range through-space and through-bond interactions in the electronic ground and excited states [4] [5]. We are aiming at a way of synthesizing chemically stable silsesquioxanes with



donor/acceptor groups as shown in 1. Very stable silsesquioxanes are those carrying Si–C substituents [1]. In 1, R is a substituent, such as an alkyl group, attached to all Si-atoms except those occupied by A or D. A and D are linked to Si *via* a Si–C bond. We report the first example of an $(-O)_3$ Si–X + Y \rightarrow $(-O)_3$ Si–Y + X substitution in symmetrical octasilsesquioxanes (XSiO_{3/2})₈ that leads directly to an $(-O)_3$ Si–C bond.

Only four examples of $(-O)_3Si-X + Y \rightarrow (-O)_3Si-Y + X$ substitution reactions (Scheme 1) have been reported for the symmetrical silsesquioxanes $(XSiO_{3/2})_8$. These



include the photochlorination of $(HSiO_{3/2})_8$ leading to $(CISiO_{3/2})_8$ and the methoxylation of this product resulting in $(CH_3OSiO_{3/2})_8$, both described in 1985 [6]. The third example is the trimethylsilylation of various hydridosilsesquioxanes [7], and we have recently described the Pd-catalyzed deuterium exchange of $(HSiO_{3/2})_8$ to $(DSiO_{3/2})_8$ [8]. It is reasonable to assume, that these reactions proceed *via* a radical-type mechanism.

An important radical-type reaction in silicon chemistry leading to the formation of a Si-C bond is the hydrosilation reaction. Provided that this reaction proceeds under retention, it would ideally suit our needs. Testing this hypothesis in the hydrosilation of hex-1-ene and of methylenecyclohexane by octa(hydridosilsesquioxane), we ended up with octa(hexylsilsesquioxane) and octa(cyclohexylmethylsilsesquioxane) being formed with a yield of at least 90%. This can be regarded as a proof that the hydrosilation does proceed under retention. It seems reasonable to assume, that the mechanism of this reaction is similar to that described for the Pd-catalyzed deuterium exchange of (HSiO_{3/2})₈ [8] [9].



The reaction presented in *Scheme 2* will lead to a great number of new oligosilsesquioxanes [10]. It appears to be suitable for designing supramolecular assemblies with silsesquioxanes as bridging components. A step-by-step route, separating unused intermediates after each reaction, is attractive [11].

Experimental. – Synthesis of Octa(1-hexylsilsesquioxane). Hydrosilation of hex-1-ene by octa(hydridosilsesquioxane): 0.25 ml (2 mmol) of hex-1-ene (*Fluka*, *p.a.*), 0.1 g (0.24 mmol) of octa(hydridosilsesquioxane) (prepared using the method by *Frye* and *Collins* [12], recrystallized twice from cyclohexane), 0.1 ml (1 µmol) of a 0.01M H₂PtCl₆ soln. in i-PrOH were put in a 10-ml round-bottom flask and heated at reflux for 5 h under N₂. A viscous yellowish liquid remained after evaporation of the solvent. Purification using size exclusion liquid chromatography [11] yielded a clear, viscous oil, from which a white solid precipitated after a few days. Yield: 90%. ¹H-NMR (300 MHz, CDCl₃): 1.800–1.550 (*m*, 5H); 1.490 (*m*, 1H); 1.320–1.040 (*m*, 3H); 1.020–0.840 (*m*, 2H); 0.564 (*d*, 2H). ¹³C-NMR (300 MHz, CDCl₃): 32.354 (CH₂); 31.583 (CH₂); 22.759 (CH₂); 22.569 (CH₂); 14.111 (CH₃); 11.991 (CH₂). MS (70 eV, 200°): 1096 (0.5, *M*⁺), 1011 (95, [*M* – C₆H₁₁]⁺), 926 (4.5, [*M* – 2C₆H₁₁]⁺). As far as comparable, spectroscopic results agree with those reported by *Andrianov and Izmailo* [13].

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Synthesis of Octa(cyclohexylmethylsilsesquioxane). Hydrosilation of methylenecyclohexane by octa(hydridosilsesquioxane): 0.25 ml (2 mmol) of methylenecyclohexane (*Fluka, purum*), 0.1 g (0.24 mmol) of octa(hydridosilsesquioxane), 0.1 ml (1 µmol) of a 0.01 M H₂PtCl₆ soln. in i-PrOH were put in a 10-ml round-bottom flask and heated at reflux for 5 h under N₂. A white solid precipitated after evaporation of the solvent. Recrystallization was performed from hexane. Yield: 90%. ¹H-NMR (300 MHz, CDCl₃): 1.440–1.210 (*m*, 8 H); 0.833 (*t*, 3 H); 0.603 (*t*, 2 H). ¹³C-NMR (300 MHz, CDCl₃): 36.198 (CH₂); 33.106 (CH); 26.585 (CH₂); 26.249 (CH₂); 21.029 (CH₂). MS (70 eV, 60°): 1192 (20, *M*⁺), 1095 (75, $[M - C_7H_{13}]^+$), 999 (5, $[M^+ - 2(C_7H_{13}]^+)$. The spectroscopic data are in excellent agreement with those previously published by *Feher* and *Budzichowski* [14].

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